



PATENT

Attorney Docket No.: MICRON.076DV1

Date: March 10, 2003

Page 1

REQUEST FOR CONTINUED EXAMINATION (RCE)

UNDER 37 C.F.R. § 1.114

Applicant: Weimin Li
Application Number: 10/033,656
Filing Date: December 27, 2001
Title: LOW DIELECTRIC CONSTANT
MATERIAL FOR INTEGRATED
CIRCUIT FABRICATION
Examiner Name: Jamie Lynn Brophy
Group Art Unit: 2822

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March 10, 2003

(Date)

Adeel S. Akhtar, Reg. No. 41,394

United States Patent and Trademark Office
P.O. Box 2327
Box RCE
Arlington, VA 22202

This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application.

1. Submission Required under 37 C.F.R. § 1.114:

- (X) Enclosed:
(X) Amendment/Reply
(X) 10 pages of Formal Drawings
(X) Return Postcard

2. Fees:

- (X) RCE fee \$750 large entity

3. Payment:

- (X) Check in the amount of \$750 to cover the above fees.
(X) The Commissioner is hereby authorized to charge any additional fees under 37 C.F.R. § 1.16 and § 1.17 which may be required, now or in the future, or credit any overpayment to Deposit Account No. 11-1410.

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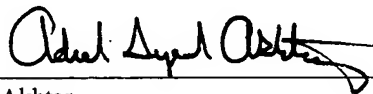
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Dated: March 10, 2003



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A-Full
PATENT
3/19/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Li
Application : 10/033,656
Filed : 27 December 2001
For : LOW DIELECTRIC CONSTANT MATERIAL
FOR INTEGRATED CIRCUIT FABRICATION
Examiner : Jamie Lynn Brophy

Group Art Unit 2822

AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION

Dear Madam:

In response to the Office Action mailed on 14 January 2003, and in connection with the Request for Continued Examination filed herewith, please enter the following amendments and consider the following remarks.

Introductory Comments

Please amend Claims 1 and 5.

Applicant has enclosed corrected formal drawings as approved by the Examiner.

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